Nanopowder synthesis of aluminum doped cadmium oxide via sol–gel calcination processing

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ABSTRACT
The structural, optical and electrical properties of undoped and Al-doped CdO powder nanostructures prepared by sol–gel calcinations method have been investigated. X-ray diffraction (XRD) results revealed that pure and Al-doped CdO have the polycrystalline with face centered cubic (FCC) structure. The crystallite size for undoped and 5, 10, 15, 20% of Al-doped CdO samples were found to be 17.2, 15.9, 16.1, 16.3 and 16.8 nm, respectively. The optical band gap of the samples were determined from the diffused reflectance spectra and \( E_g \) values for undoped and 5, 10, 15, 20% of Al-doped CdO samples were found to be 1.89, 2.07, 2.03, 2.07 and 2.12 eV, respectively. The electrical conductivities of pure and Al-doped CdO were measured in the temperature range (290–420 K) and their temperature dependence was analyzed according to Arrhenius relation. The electrical conductivity results indicate that the electrical conductivity mechanism is controlled by thermally activated processes. The results showed that sol–gel calcinations technique can be effectively used to produce undoped and doped nanopowders.

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1. Introduction
Thin films of transparent conductive oxides (TCO) such as zinc oxide, indium–tin oxide, tin oxide and cadmium oxide have been extensively studied because of their use in semiconductor optoelectronic device applications [1]. In recent years, the metal oxide semiconductor materials have attracted much attention owing to their potential applications in electronic and photovoltaic devices. CdO is n-type semiconductor with a rock-salt crystal structure (FCC) and possesses a direct band gap of 2.2 eV. Its high optical transmittance in the visible region of the solar spectrum along with a moderate refractive index make it useful for various applications such as solar cells, transparent electrodes, phototransistors, photodiodes, gas sensors, etc. [2,3]. CdO has received a considerable attention as the transparent electrode of CdTe-based thin film solar cells because its electro-optical properties compare with those of the traditional TCOs [4]. But, cadmium oxide is not a popular TCO material due to its low optical band gap. While, CdO is a particularly interesting material because it is one of the semiconducting oxides with high carrier mobility, and has great potential for using in optoelectronic devices.

CdO has a great technological interest due to their high-quality electrical and optical properties. Doped CdO with different dopants (F, In, Ga, Al, Fe, Cd, Zn, etc.), as multicomponent oxides constituted of CdO, have been used in several applications: photovoltaic devices, gas sensors, phototransistors and diodes, etc. [5,6]. Different methods have been adopted to deposit doped and pure CdO films such as metalorganic chemical vapor deposition (MOCVD), sputtering [7], electron beam evaporation [8], sol–gel [9,10], pulsed laser deposition [11], dc magnetron sputtering [12], radio-frequency sputtering [13], spray pyrolysis [14], and chemical bath deposition [15].

Among this methods of preparation pure and doped CdO, the sol–gel route method is one of the most promising available methods for synthesizing nanoparticles of controlled size and morphology. The sol–gel technique is one of the most promising tools in material science. The versatility of this method allows us to design desired materials at the lower temperatures, alternatively to conventional methods for manufacturing materials. The synthetic route provided by this system is the most feasible one for designing materials possessing unique properties. Generally, it is a process concerning transition of a system from liquid ‘sol’ (the colloidal suspension of particles) into solid ‘gel’. On the other hand sol–gel technique is simpler and cost-effective. Accordingly, this method is adopted and applied to sensitize both of pure and Al-doped CdO nanostructures in the present study.

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In present work, we have synthesized pure and Al-doped CdO by sol–gel calculations route. X-ray diffraction patterns were used to identify the phases of pure and Al-doped CdO. Diffused reflectance as a new method was used to characterize the optical band gap of the powder samples. Dc electrical conductivity was studied to analyze the electrical conduction mechanism.

2. Experimental

2.1. Preparation of the samples

Solutions of undoped and Al–doped CdO were prepared by sol–gel route method as follows: Undoped CdO precursor solution was prepared by the following procedure: (i) the cadmium acetate was dissolved in 2-methoxyethanol (MTE) (0.5 M) at a constant magnetic stirring for 10 min and then, monoethanolamine (0.5 M) (C₂H₇NO, MEA) as stabilizer was added to the solution during the stirring; (ii) The solution was stirred constantly for two hours. CdO precursor containing Al-dopants were prepared as follows: Undoped CdO precursor solution was prepared by the following procedure: (i) the cadmium acetate was dissolved in 2-methoxyethanol (MTE) (0.5 M) (C₂H₇NO, MEA) as stabilizer was added to the solution during the stirring; (ii) The solution was stirred constantly for two hours. CdO precursor containing Al-dopants were prepared as follows: (0.5 M) cadmium acetate and (0.5 M) with different percentages (5, 10, 15 and 20%) aluminum nitrate (Al(NO₃)₂·9H₂O), were dissolved in MTE for 10 min. Afterwards, MEA was added drop by drop with continuous stirring and the final solution was stirred for 2 h at 60 °C. The obtained gels were calcinated in a tube furnace for 2 h at 700 °C, respectively. The powders samples were prepared in form of disc to characterizations.

2.2. Characterization

X-ray diffraction patterns of the samples were obtained with a D8 BRUKER X-ray diffractometer using CuKα radiations (λ = 1.54059 Å). The structural properties of the powder samples were investigated by Park System XE-100E atomic force microscopy (AFM). The diffuse reflectance spectra of the investigated samples were performed using a Shimadzu UV-VIS-NIR 3600 spectrophotometer using an integrating sphere attachment.

3. Results and discussion

3.1. Structural properties of pure and Al-doped CdO nanostructures

The XRD patterns of pure and Al-doped CdO nanostructures powder samples are shown in Fig. 1. The different peaks in the XRD pattern of the samples were appeared at 2θ values, 32.995°, 38.292°, 55.260°, 65.921° and 69.293° corresponding to (1 1 1), (2 0 0), (2 2 0), (3 1 1) and (2 2 2) reflections, respectively. XRD patterns revealed that pure and Al-doped CdO have faced centered cubic (FCC) structure. The relatively stronger intensity peaks at 2θ equal 32.995 and 38.292, in which their intensities were changed by Al dopant. It is clear that the preferred orientation changes from (1 1 1) to (2 0 0) plane with changing the Al doping. The same behaviour was observed in the pure and Al-doped CdO prepared by pulsed laser deposition and by sol–gel dip coated [11,16]. X-ray diffraction results confirmed that the CdO is the only phase inside these compounds. The lattice constant a was obtained from inter-planer spacing of dₕₖₗ value of the (1 1 1) and (2 0 0) peaks using the following equation [17]:

\[ d_{hkl} = \frac{a}{\sqrt{h^2 + k^2 + l^2}}. \]  (1)

The mean value of the calculated lattice constant a for the undoped and Al-doped CdO is approximately equals 4.833 Å. The obtained data is in good agreement with JCPDS card No.78-0592 [18] which equal 4.694 Å.

X-ray diffraction measurements were used to determine the nature of the powder growth and the structural characteristics of undoped and Al-doped CdO. The crystallite size of the investigated materials can be calculated from the X-ray spectrum by means of full width at half maximum (FWHM) method known as Scherrer’s equation [19]:

\[ D = \frac{0.9 \lambda}{\beta \cos \theta} \]  (2)

where β is the full-width at half maximum of the XRD peak appearing at the diffraction angle θ. The crystallite size of undoped and Al-doped CdO samples is given in Table 1. It is clear from Table 1

<p>| Table 1 |
|-----------------|-----------------|-----------------|-----------------|
|                | Crystallite size, D (nm) | Strain, ε (×10⁻⁵) for (1 1 1) plane | The dislocation density, δ (×10⁻² Å⁻²) |</p>
<table>
<thead>
<tr>
<th>Crystallite size, D (nm)</th>
<th>(1 1 1) plane</th>
<th>(2 0 0) plane</th>
<th>(1 1 1) plane</th>
<th>(2 0 0) plane</th>
<th>(1 1 1) plane</th>
<th>(2 0 0) plane</th>
<th>(1 1 1) plane</th>
<th>(2 0 0) plane</th>
</tr>
</thead>
<tbody>
<tr>
<td>Pure CdO</td>
<td>17.2</td>
<td>117.457</td>
<td>115.488</td>
<td>3.380</td>
<td>117.457</td>
<td>115.488</td>
<td>3.380</td>
<td></td>
</tr>
<tr>
<td>5% Al-doped CdO</td>
<td>15.9</td>
<td>124.165</td>
<td>124.934</td>
<td>3.956</td>
<td>124.165</td>
<td>124.934</td>
<td>3.956</td>
<td></td>
</tr>
<tr>
<td>10% Al-doped CdO</td>
<td>16.1</td>
<td>122.675</td>
<td>124.225</td>
<td>3.858</td>
<td>122.675</td>
<td>124.225</td>
<td>3.858</td>
<td></td>
</tr>
<tr>
<td>15% Al-doped CdO</td>
<td>16.3</td>
<td>121.477</td>
<td>121.155</td>
<td>3.764</td>
<td>121.477</td>
<td>121.155</td>
<td>3.764</td>
<td></td>
</tr>
<tr>
<td>20% Al-doped CdO</td>
<td>16.8</td>
<td>117.883</td>
<td>118.321</td>
<td>3.543</td>
<td>117.883</td>
<td>118.321</td>
<td>3.543</td>
<td></td>
</tr>
</tbody>
</table>
that the crystallite size is changed unsystematically for a regular increase of aluminum concentration. Accordingly, it is possible to calculate both of the dislocation density $\delta$, the strain $\varepsilon$ and the texture coefficient $T_c$ to have more information about the structure characteristics of undoped and Al-doped CdO nanostructured powders from the following equations [20–23]:

$$\delta = \frac{n}{D^2}$$  \hspace{1cm} (3)

$$\varepsilon = \frac{\beta \cos \theta}{4}$$  \hspace{1cm} (4)

$$T_c = \frac{I(hkI)/I_0(hkI)}{(1/N) \sum I(hkI)/I_0(hkI)}$$  \hspace{1cm} (5)

where $n$ is taken as unity at a minimum dislocation density, $I_0(hkI)$ is the intensity value of $(hkI)$ plane from JCDPS card No. 78-0592, $I(hkI)$ is the measured intensity for each $(hkI)$ plane and $N$ is the number of diffraction peaks. The values of dislocation density $\delta$ and the strain $\varepsilon$ of $(111)$ and $(200)$ planes for undoped and Al-doped CdO samples are given in Table 1. Fig. 2 shows the variation of the texture coefficient for different undoped and Al-doped CdO for $(111)$, $(200)$, $(220)$, $(311)$ and $(222)$ planes. Among these planes, $T_c(111)$ and $T_c(200)$ exhibit the same trend as increased with increasing the Al-dopants of (10%) and then decreased again, while the other planes $T_c(220)$, $T_c(311)$ and $T_c(222)$ show opposite trend, in which it is decreased until reached a minimum at Al-dopant of (10%) and then increased again. This indicates the occurrence of crystal reorientation effect due to the change of the Al-dopants concentration [24].

The structural properties of the Al doped CdO samples were investigated by AFM. The AFM images of $(40 \mu m \times 40 \mu m)$, inset: $(5 \mu m \times 5 \mu m)$ and three (3D) dimensional for pure CdO, (B) 5%, (C) 10%, (D) 15% and (E) 20% Al-doped CdO powder nanostructures are shown in Fig. 3a and b, respectively. As seen in Fig. 3a, the samples are consisted of nanoparticles in clusters (Nanoparticle Clusters). Type of nanostructure particles is like spherical as shown in Fig. 2b. The diameter of clusters of undoped and 5, 10,
15, 20% Al-doped CdO were 420, 335, 365, 350 and 330 nm, respectively. The diameter of the clusters is decreased with Al dopant except for 10% dopant.

3.2. Determination of optical band gap of pure and Al-doped CdO nanostructures

To determine the optical band gap of pure and Al-doped CdO nanostructures, the diffuse reflectance spectra for the powder samples were measured as shown in Fig. 4. As seen in Fig. 4, the reflectance of the samples increases with increasing the wavelengths. In order to determine the precise value of optical band gap of pure and Al-doped CdO nanostructures, the reflectance values were converted to absorbance by application of the Kubelka–Munk function [25–27]. The Kubelka–Munk theory is generally used for analyzing the diffuse reflectance spectra obtained from a weakly absorbing samples. It provides a correlation between reflectance and concentration. The concentration of an absorbing species can be determined using the Kubelka–Munk formula [25–27]:

$$ F(R) = \frac{(1 - R)^2}{2R} \quad (6) $$

where $R$ is the diffused reflectance. $F(R)$ is Kubelka–Munk function which corresponds to the absorbance. $F(R)$ values were converted to the linear absorption coefficient by the following relation [27–29],

$$ \alpha = \frac{F(R)}{t} = \frac{\text{Absorbance}}{t} \quad (7) $$

where $t$ is the thickness of pure and Al-doped CdO. The optical transitions in semiconductor materials are taken place by direct and indirect transitions. The fundamental absorption, which corresponds to electron excitation from the valence band to conduction band, can be used to determine the value of the optical band gap $E_g$ and it is related to the optical transition. The relation between the absorption coefficient $\alpha$ and the incident photon energy $h\nu$ can be written as [30,31]:

$$ (a h \nu) = A (h \nu - E_g)^n \quad (8) $$

where $A$ is a constant depending on the transition probability and $n$ is an index that characterizes the optical absorption process. The parameter $n$ has the value 1/2 for the direct allowed transition and has the value 2 for the indirect allowed transition. Eq. (8) can be rewritten as [27]

$$ \frac{F(R) h \nu}{t} = A (h \nu - E_g)^n \quad (9) $$

The optical band gap values for pure and Al-doped CdO obtained by extrapolating the linear portion of the plots of $(F(R) h \nu/t)^2$ versus the photon energy to $h \nu = 0$ as shown in Fig. 5. These plots are shown in Fig. 5. The values of the obtained band gap $E_g$ for pure and Al-doped CdO are given in Table 2. It is seen that the optical band gap of the samples slightly increases with the increase of Al content inside the pure samples. Generally, one can expect an increase in band gap of CdO doped with Al due to an increase in carrier concentrations which lead to the Burstein–Moss effect [32]. The optical band gap of the studied pure and Al-doped CdO samples is lower than the previously published work about the thin film samples of these compounds. Up to our knowledge, no data reported about the bandgap of the pure and Al-doped CdO nanopowders based on the diffuse reflectance calculations.

3.3. Electrical conductivity of pure and Al-doped CdO nanostructures

Electrical conductivity reveals reliable information about the transport phenomenon of Al doped CdO samples. The electrical conductivities of pure and Al-doped CdO were measured in the temperature range (290–420 K) and their temperature dependence

### Table 2

<table>
<thead>
<tr>
<th>Sample</th>
<th>$E_g$ (eV)</th>
<th>$\sigma_{RT}$ (S/cm) at 303 K</th>
<th>$E_{\tau 1}$ (meV)</th>
<th>$E_{\tau 2}$ (meV)</th>
</tr>
</thead>
<tbody>
<tr>
<td>Pure CdO</td>
<td>1.89</td>
<td>227.854 × 10^{-3}</td>
<td>0.24</td>
<td>–</td>
</tr>
<tr>
<td>5% Al-doped CdO</td>
<td>2.07</td>
<td>69.029 × 10^{-3}</td>
<td>0.44</td>
<td>–</td>
</tr>
<tr>
<td>10% Al-doped CdO</td>
<td>2.03</td>
<td>43.836 × 10^{-3}</td>
<td>0.30</td>
<td>–</td>
</tr>
<tr>
<td>15% Al-doped CdO</td>
<td>2.07</td>
<td>46.254 × 10^{-3}</td>
<td>1.53</td>
<td>–</td>
</tr>
<tr>
<td>20% Al-doped CdO</td>
<td>2.12</td>
<td>147.365 × 10^{-3}</td>
<td>0.29</td>
<td>0.72</td>
</tr>
</tbody>
</table>
The obtained results indicate that Al-doped CdO samples are nanostructure powder materials.

Acknowledgements

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References


Fig. 6. Plots of ln σ vs 1000/T of pure CdO, 5%, 10%, 15%, and 20% Al-doped CdO powder nanostructures.